

EUVL Mask Pellicle TW G

February 21st, 2016 1:30pm start



	Speaker	Affiliation
Welcome	Emily Gallagher	imec
Session 1: Pellicle membranes		
ASML's progress for pSi pellicle development	Dan Smith	ASML
Intel: Critical gaps and priorities?	Ted Liang	Intel
IBM: EUV pellicle update	Dario Goldfarb	IBM
imec: EUV pellicle project	Emily Gallagher	imec
Panel discussion 1	all speakers Session 1	
break		
Session 2: Pellicle measurements		
ASML: EUV Pellicle requirements update	Derk Brouns	ASML
EUV Tech: pellicle metrology	Rupert Perera	EUV Tech
RWTH Aachen: Measuring thin films in the EUV	Serhiy Danyluk	RWTH Aachen
LBNL: EUV pellicle transmission measurements	Eric Gullikson	LBNL
PTB: Scattering measurements	Christian Laubis	PTB
Panel discussion 1 / wrap-up	all speakers Session 2	

Location: Crystal Room, Fairmont Hotel, San Jose, CA

Chair: emily.gallagher@imec.be

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